Particle-free engineering in SHINE superconducting LINAC vacuum system

Abstract:

The Shanghai high-repetition-rate XFEL and extreme light facility is superconducting accelerat-ing structures of high gradients, whose performance is closely related to the cleanliness of superconducting cavities. Therefore, the beam line vacuum system has extremely high requirement for particle free to avoid particles down to submicrometric scale. To control parti-cle contamination, particle-free environment has been built for cavity string assembly and other beam line vacuum components installation, clean assembly criteri-on has been established. Furthermore, the particle gener-ation of vacuum components (valve, pump, et al.) has been studied. Moreover, dedicated equipment and com-ponent (slow pumping & slow venting system, non-contact RF shielding bellow) have been developed for particle-free vacuum system.

INTRODUCTION

SHINE is a new hard-XFEL facility under construction in China, which is designed to accelerate electron beams to 8GeV by 600 1.3 GHz 9-cell cavities working in continuous wave mode, and the cavities is installed in 75 cryomodules¹. Cleanliness is essential in the preparation of field emission free, high gradient, low loss superconducting cavities², therefore, not only the cavities but also the beamline vacuum components adjacent to cryomodules has extremely high cleanness requirement. The design, fabrication, cleaning, assembly, testing process of these components must be followed the cleanliness requirement.

In SHINE linac, the total length of particle-free zone is 1.2 km, including cryomodules and room temperature (RT) beamline. For cryomodules, the vertical test of single cavity, cavity string assembly and cryomodule horizontal test are all carried out in SHINE. For RT beamline vacuum components, most precleaning is performed at supplies. For integrated equipment like collimators, profile monitors, wire scanners, e.g., the particle-free assembly is carried out at supplies. For standard components like vacuum gauges, valves, pumps, the cleaning before final assembly is carried out in SHINE.

INFRASTRUCTURES

A 400 m² cleanroom have been built in 2019 for SHINE superconducting cavity string assembly, which has 300 m² ISO 4 class area and 100 m² ISO 5 class area.

The cleanroom includes ultrasonic cleaning, high press rinsing (HPR), cavity drying areas, and the cavity string assembly area is capable for up to 8 persons to assembly 2 cavity strings at the same time.



booths, so as to obtain a local cleanness higher than ISO 5 class, while the direction of laminar flow of each booth is various according on specific working conditions.

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Several kinds of full-automatic slow pumping & slow venting (SPSV) systems have been developed for particle-free vacuum system. The mass flow rate in pumping and venting procedures could be set down to 0.2 SLM, so as to avoid turbulent flow and reduce the probability of contamination and particulates transporting in vacuum system.



To avoid friction between metals which could generate the large number of particles, a noncontact type RF shielding bellow design is adopted in room temperature beamline vacuum. This RF bellow has 2 copper tube nested inside and out, with a radial direction offset 2 mm.

EQUIPMENTS & COMPONENTS

More than 200 ion pumps will be installed onto the particle-free vacuum system, which were cleaned and assembled follow the particle-free criterion, the body of pump was rinsed in flowing super purified water, and baked out in ISO 6 class cleanroom, after that purified nitrogen gas blowing cleaning were carried out before final assembly in ISO 4 class cleanroom.

The valves used in SHINE beamline vacuum is allmetal, therefore, valve open/close action always generate particles. Tests have been carried out for angle valves and gate valves, the results show that every single open/close action could generate dozens of particles at 0.3 and 0.5 um size.



SINAP







To monitor the particle generated in the process of getter pump activation, a in-vacuum particle counter (In-line particle sensor, IPS, CyberOptics) was used, which can measure particles greater than 0.16 µm size, with less than 5 false counts per hour. However, the inlet of the measuring area of IPS is smaller than 1 cm², showed in Fig.5a, the possibility of particle in vacuum transport to measuring area is quite low, to monitoring the particles, IPS has been installed right under a getter pump (Saes Z400), the setup is showed in Fig5c. During the process of degas of Z400, the voltage range is 0 to 5 V, 1×10^{-3} Pa, no particle was detected. Afterwards, the voltage was raised to 15V gradually, while the pressure was 5×10^{-4} Pa, few particle was detected until the voltage and current of Z400 reached 14.9 V and 3.9 A, respectively. The count of particle (size 0.16, 0.3, 0.5, >0.5 um) is several hundred per minute, showed in Fig.5d. The number of counts lasted for 5 minutes, and dropped to 300 pc/minute.

In another in-vacuum test of Saes HV1600 getter pump,

the measuring area of IPS is not right under the pump, therefore nearly no particle was detected.

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